

CLAIMS

We claim:

1. An apparatus for supercritical processing of a workpiece comprising:
 - a. a transfer module having an entrance;
 - b. a supercritical processing module coupled to the transfer module;
 - c. a non-supercritical processing module coupled to the transfer module; and
 - d. a transfer mechanism coupled to the transfer module, the transfer mechanism configured to move the workpiece between the entrance, the supercritical processing module, and the non-supercritical processing module.
2. The apparatus of claim 1 wherein the entrance of the transfer module comprises a hand-off station.
3. The apparatus of claim 2 wherein the entrance of the transfer module further comprises an additional hand-off station.
4. The apparatus of claim 1 wherein the transfer module operates in vacuum and further wherein the entrance of the transfer module comprises a loadlock.
5. The apparatus of claim 4 wherein the entrance of the transfer module further comprises an additional loadlock.
6. The apparatus of claim 1 wherein the non-supercritical processing module comprises a semiconductor processing module.
7. The apparatus of claim 6 wherein the semiconductor processing module is selected from the group consisting of an etch module, a physical vapor deposition module, a chemical vapor deposition module, an electroplating module, a chemical mechanical planarization module, a photolithography module, and an

5 other semiconductor processing module.

1 8. The apparatus of claim 1 wherein the transfer mechanism comprises a
2 robot.

1 9. The apparatus of claim 8 wherein the transfer module comprises a circular
2 configuration.

1 10. The apparatus of claim 9 wherein the robot comprises a central robot, the
2 central robot occupying a center of the circular configuration.

1 11. The apparatus of claim 8 wherein the transfer module comprises a track
2 configuration.

1 12. The apparatus of claim 11 wherein the robot comprises a tracked robot, the
2 tracked robot comprising the robot coupled to a track such that the robot moves
3 along the track in order to reach the supercritical processing module and the non-
4 supercritical processing module located along the track.

1 13. The apparatus of claim 8 wherein the robot comprises an extendable arm
2 and an end effector.

1 14. The apparatus of claim 13 wherein the robot further comprises an
2 additional arm and an additional end effector.

1 15. The apparatus of claim 1 wherein the first supercritical processing module
2 comprises a pressure vessel.

1 16. The apparatus of claim 15 wherein the pressure vessel comprises a
2 workpiece cavity and a pressure vessel entrance, the workpiece cavity holding the
3 workpiece during supercritical processing, the pressure vessel entrance providing
4 ingress and egress for the workpiece.

1 17. The apparatus of claim 16 wherein the transfer mechanism is configured to
2 place the workpiece in the workpiece cavity.

1 18. The apparatus of claim 16 further comprising an ante-chamber coupling
2 the transfer module and the supercritical processing module.

1 19. The apparatus of claim 1 further comprising means for pressurizing the
2 supercritical processing module.

1 20. The apparatus of claim 19 wherein the means for pressurizing comprises a
2 CO₂ pressurizing configuration which comprises a CO₂ supply vessel coupled to a
3 pump which is coupled to the supercritical processing module.

1 21. The apparatus of claim 18 further comprising means for sealing, the means
2 for sealing operable to seal the pressure vessel entrance.

1 22. The apparatus of claim 1 wherein the transfer module further comprises
2 means for producing a vacuum within the transfer module.

1 23. The apparatus of claim 1 wherein the transfer module further comprises
2 means for maintaining a slight positive pressure in the transfer module relative to
3 a surrounding environment.

1 24. The apparatus of claim 23 wherein the means for maintaining the slight
2 positive pressure in the transfer module comprise an inert gas injection
3 arrangement.

1 25. The apparatus of claim 1 further comprising means for controlling such
2 that the means for controlling directs the transfer mechanism to move the
3 workpiece.

1 26. A method of supercritical processing a workpiece comprising the steps of:
2 a. transferring the workpiece from an entrance of a transfer module

3 into a transfer module;

- 4 b. transferring the workpiece to a supercritical processing module;
5 c. processing the workpiece in the supercritical processing module;
6 d. transferring the first workpiece to the non-supercritical processing
7 module;
8 e. processing the workpiece in the non-supercritical processing
9 module; and
10 f. returning the workpiece to the entrance of the transfer module.

1 27. The method of claim 26 wherein the entrance of the transfer module
2 comprises a hand-off station.

10 28. The method of claim 27 wherein the entrance of the transfer module
2 further comprises an additional hand-off station.

- 1 29. An apparatus for supercritical processing a workpiece comprising:
2 a. means for transferring the workpiece configured to transfer the
3 workpiece into a transfer module;
4 b. means for supercritical processing configured such that in
5 operation the means for transferring transfers the workpiece to the means
6 for supercritical processing and further such that in operation the means
7 for supercritical processing processes the workpiece; and
8 c. means for non-supercritical processing configured such that in
9 operation the means for transferring transfers the workpiece to the means
10 for non-supercritical processing and further such that in operation the
11 means for non-supercritical processing processes the workpiece.

- 1 30. An apparatus for supercritical processing of a workpiece comprising:
2 a. a hand-off station;
3 b. a supercritical processing module coupled to the hand-off station;
4 c. a non-supercritical processing module coupled to the hand-off
5 station; and
6 d. a transfer mechanism coupled to the hand-off station, the transfer

7 mechanism configured to move the workpiece between the entrance, the
8 supercritical processing module, and the non-supercritical processing
9 module.

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